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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/707,122	11/21/2003	Lawrence A. Clevenger	FIS920030220US1	1121
32074	7590 03/22/2006		EXAMINER	
INTERNATIONAL BUSINESS MACHINES CORPORATION			CHEN, JACK S J	
DEPT. 18G				
BLDG. 300-48	82		ART UNIT	PAPER NUMBER
2070 ROUTE	52		2813	
HOPEWELL	JUNCTION, NY 12533		DATE MAILED 02/20/200	,

Please find below and/or attached an Office communication concerning this application or proceeding.

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		Application No.	Applicant(s)			
		10/707,122	CLEVENGER ET AL.			
	Office Action Summary	Examiner	Art Unit			
		Jack Chen	2813			
Period fo	The MAILING DATE of this communication app or Reply	ears on the cover sheet with the c	orrespondence address	*		
WHIC - Exter after - If NC - Failu Any	ORTENED STATUTORY PERIOD FOR REPLY CHEVER IS LONGER, FROM THE MAILING DANSIONS of time may be available under the provisions of 37 CFR 1.13 SIX (6) MONTHS from the mailing date of this communication. Operiod for reply is specified above, the maximum statutory period were to reply within the set or extended period for reply will, by statute, reply received by the Office later than three months after the mailing ed patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tin vill apply and will expire SIX (6) MONTHS from , cause the application to become ABANDONE	N. nely filed the mailing date of this communication. D (35 U.S.C. § 133).			
Status	•			÷		
1)	Responsive to communication(s) filed on					
· —	This action is FINAL . 2b) This action is non-final.					
3)□	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is					
	closed in accordance with the practice under E	x parte Quayle, 1935 C.D. 11, 4	53 O.G. 213.			
Dispositi	ion of Claims					
5)□ 6)⊠ 7)⊠	Claim(s) 1,3-6,8 and 11-24 is/are pending in the 4a) Of the above claim(s) 11-24 is/are withdraw Claim(s) is/are allowed. Claim(s) 1 and 3-5 is/are rejected. Claim(s) 6 and 8 is/are objected to. Claim(s) are subject to restriction and/or	vn from consideration.				
Applicati	ion Papers					
	The specification is objected to by the Examine	r.				
•	The drawing(s) filed on is/are: a) acce		Examiner.			
	Applicant may not request that any objection to the	drawing(s) be held in abeyance. See	e 37 CFR 1.85(a).			
11)	Replacement drawing sheet(s) including the correct The oath or declaration is objected to by the Ex		•			
Priority (under 35 U.S.C. § 119					
12)□ a)	Acknowledgment is made of a claim for foreign All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the priority documents application from the International Bureau See the attached detailed Office action for a list	s have been received. s have been received in Applicati rity documents have been receive u (PCT Rule 17.2(a)).	ion No ed in this National Stage			
2) Notice 3) Information	ce of References Cited (PTO-892) ce of Draftsperson's Patent Drawing Review (PTO-948) mation Disclosure Statement(s) (PTO-1449 or PTO/SB/08) er No(s)/Mail Date	4) Interview Summary Paper No(s)/Mail D 5) Notice of Informal F 6) Other:				

DETAILED ACTION

In response to the communication filed on October 13, 2005, claims 1, 3-6, 8 are active in this application and claims 11-24 are withdrawn from further consideration.

Claim Rejections - 35 USC § 112

- 1. The following is a quotation of the second paragraph of 35 U.S.C. 112:
 - The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.
- Claim 4 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for 2. failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

Re claim 4, lines 2-3, the phrase "said liner layer deposited on the ILD" lacks antecedent basis (note: claim 1 requires depositing the liner layer in the interconnect aperture).

Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- Claims 1, 3-5 are rejected under 35 U.S.C. 102(b) as being anticipated by Gopalraja et 4. al., U.S./6,277,249.

Gopalraja et al. disclose a method for forming an interconnect structure, which comprises providing a lower electrical contact including a lower interconnect member 212 (fig. 14);

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depositing an ILD 214 and forming an interconnect aperture 216 therein extending down to make contact with said lower interconnect member (fig. 14); depositing a liner layer 218 in said interconnect aperture (fig. 14); removing said liner layer on at least the bottom surface of said interconnect aperture (fig. 15), thereby exposing a top surface of said lower interconnect member; bombarding (i.e. by sputtering process, etc.) said top surface of said lower interconnect member with ions (i.e. Ar, etc., col. 15, lines 45-57 and col. 17, line 5) such that material is removed from the interface of said lower interconnect member and the bottom surface of said interconnect aperture (fig. 15), thereby forming a second aperture 224 (fig. 15) within said lower interconnect member having a shape with substantially no horizontal surfaces (fig. 15); and depositing conductive material 226 (fig. 15, also see fig. 16 and col. 15) in said interconnect aperture, thereby establishing a joint between said lower interconnect member and an upper interconnect member formed by said conductive material in said interconnect aperture (figs 15-16), see figs. 1-16 and cols. 1-18 for more details.

Re claim 3, the material of said lower interconnect member 212 is selected from the group consisting of Cu, W, Al and other conducting materials (i.e., Cu; fig. 14 and col. 14, lines 1-10).

Re claim 4, due to 112 problems, as best can be understood by the examiner is as following: the material of said liner 218 is selected from the group consisting of TaN, Ta, Ti, Ti(Si)N and W (i.e., Ta/TaN etc., fig. 14 and col. 15, lines 55-65 and col. 4, lines 5-10).

Re claim 5, a gas source for ion bombardment is selected from the group consisting of Ar, He, Ne, Xe, N2, H2, NH3, N2H2 (i.e. Ar, etc., col. 15, lines 45-57 and col. 17, line 5).

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Claim Rejections - 35 USC § 103

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5. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all

obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person

such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the

manner in which the invention was made.

6. This application currently names joint inventors. In considering patentability of the

claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various

claims was commonly owned at the time any inventions covered therein were made absent any

evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out

the inventor and invention dates of each claim that was not commonly owned at the time a later

invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c)

and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

Allowable Subject Matter

7. Claims 6 and 8 are objected to as being dependent upon a rejected base claim, but would

be allowable (claims 6 and 8 are allowed for reasons deemed to be of record) if rewritten in

independent form including all of the limitations of the base claim and any intervening claims.

Conclusion

8. Applicant's amendment necessitated the new ground(s) of rejection presented in this

Office action. Accordingly, THIS ACTION IS MADE FINAL. See MPEP § 706.07(a).

Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

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A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jack Chen whose telephone number is (571)272-1689. The examiner can normally be reached on Monday-Friday (9:00am-6:30pm) alternate Monday off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Carl W. Whitehead can be reached on (571)272-1702. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Jack Chen

Primary Examiner

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March 17, 2006